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					FIS920030350US1		Not Yet Assigned		
	INFO	RMATION DISCLOSUR			Applicant(s) Chen et al.				
(Use several sheets if necessary)					Filing Date		Group Art Unit Unknown		
					Concurrently Herewith				
	_			U.S. PAT	ENT DOCUMENTS				
•EXAMINER	REF	DOCUMENT NUMBER	DATE	NAME		CLASS	SUBCLASS	FILING	DATE
INITIAL V	,	<u> </u>	06/26/2001	Chu et al.			SUBCLASS	IF APPR	DPRIATE
		6,251,751				-	-		
<u> </u>		6,375,749	04/23/2002	Boydston et al.			ļ	·	
CX		6,348,420	02/19/2002	Raaijmakers et al.			<u> </u>		
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			··-	FOREIG	N PATENT DOCUMENT	s		L	
	REF	EP DOCUMENT NUMBER DATE			COUNTRY		SUBCLASS	Translation	
	N.E.F	JOCUMENT NUMBER	DATE	COUNTRY		CLASS	SUBCLASS	YES NO	
L			<u> </u>	OTHER	DOCUMENTS (Includia	ng Author, Title, L	Date, Pertinent Pa	ges, Etc.)	<u></u>
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		http://www.e-insite.net	/semiconductor/ir	idex.asp?la	yout=articlePri				
EXAMINER Chusty Horack DATE CONSIDERED 4/7/05									

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.